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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/826,898	04/16/2004	Hiroshi Hasegawa	10873.1432US01	10873.1432US01 2218	
53148	7590 04/03/2006		EXAMINER		
HAMRE, SCHUMANN, MUELLER & LARSON P.C.			WON, BUMSUK		
P.O. BOX 2902-0902 MINNEAPOLIS, MN 55402			ART UNIT	PAPER NUMBER	
WIN WEST C	, MIT 33 102		2879		
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Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)		
	. 10/826,898	HASEGAWA ET AL.		
Office Action Summary	Examiner	Art Unit		
	Bumsuk Won	2879		
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address		
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period w Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 6(a). In no event, however, may a reply be tim rill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONEI	I. they filed the mailing date of this communication. D (35 U.S.C. § 133).		
Status ·				
1)⊠ Responsive to communication(s) filed on <u>08 Fe</u> 2a)⊠ This action is FINAL . 2b)□ This 3)□ Since this application is in condition for allowant closed in accordance with the practice under E	action is non-final. ace except for formal matters, pro			
Disposition of Claims				
4) ⊠ Claim(s) 1-7 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1-7 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/or		*		
Application Papers		1		
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the Replacement drawing sheet(s) including the correction 11) The oath or declaration is objected to by the Examine 11.	epted or b) objected to by the Edrawing(s) be held in abeyance. See ion is required if the drawing(s) is obj	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).		
Priority under 35 U.S.C. § 119				
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Application ity documents have been receive I (PCT Rule 17.2(a)).	on No ed in this National Stage		
Attachment(s) 1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)		
2) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/Mail Da			

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DETAILED ACTION

Claim Rejections - 35 USC § 102

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 2, 5, 6 and 7 are rejected under 35 U.S.C. 102(b) as being anticipated by Trinchero (EP 0 889 500) which is Applicant's admitted prior art.

Regarding claim 1, Trinchero discloses an electron gun (figure 2) comprising: cathodes (34); a control electrode (36); an accelerating electrode (40); a first focusing electrode (44); a second focusing electrode (46) facing the first focusing electrode via a gap (45); a system for supplying (paragraph 57, line 12, "Vrocus) the first and second focusing electrode with equal electric potentials (paragraph 57, lines 9·12); and an anode electrode (48), wherein cathodes, the control electrode, the accelerating electrode, a first focusing electrode, a second focusing electrode, and the anode electrode are disposed in this order (figure 2), and an electron beam passing aperture (figure 4, 47, page 3, lines 17·24) provided in a surface of the first focusing electrode (44) facing the second focusing electrode (46) and a surface of the second focusing electrode facing the first focusing electrode is a single opening (47, page 3, line 18) common to three electron beams.

Regarding claim 2, Trinchero discloses the electron beam passing apertures (figures 2 and 4, 47) provided in both of the surface of the first focusing electrode

(44) facing the second focusing electrode (46) and the surface of the second focusing electrode facing the first focusing electrode is a single opening common to three electron beams (page 3, lines 17-24).

Regarding claim 5, Trinchero discloses both ends of the single opening (figure 4, 47) in a horizontal direction have a circular arc shape.

Regarding claim 6, Trinchero discloses a cathode ray tube device (figure 1) comprising: a cathode ray tube (figure 1) comprising: an envelope having a front panel and a funnel, and an electron gun (26) inside a neck portion of the funnel, the electron gun comprising: a first focusing electrode (44), a second focusing electrode (46) facing the first focusing electrode via a gap (45), and a system for supplying (paragraph 57, line 12, "V_{FOCUS}) the first and second focusing electrode with equal electric potentials (paragraph 57, lines 9-12); and a scanning velocity modulation coil (54, 56) provided on an outer surface of the neck portion and near the first and second focusing electrode, wherein an electron beam passing aperture (figure 4, 47, page 3, lines 17-24) provided in a surface of the first focusing electrode (44) facing the second focusing electrode (46) and a surface of the second focusing electrode facing the first focusing electrode is a single opening (47, page 3, line 18) common to three electron beams.

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Regarding claim 7, Trinchero discloses an electron gun (figure 2) comprising: cathodes (34); a control electrode (36); an accelerating electrode (40); a first focusing electrode (44); a second focusing electrode (46) facing the first focusing electrode via a gap (45); a system for supplying (paragraph 57, line 12, "V_{FOCUS}) the first and second focusing electrode with equal electric potentials (paragraph 57, lines 9-12); and an anode electrode (48); a prefocus lens (42) formed between the accelerating electrode and the first focusing electrode; and a main lens (page 2, lines 55-56) formed between the second focusing electrode and the anode electrode, wherein cathodes, the control electrode, the accelerating electrode, a first focusing electrode, a second focusing electrode, and the anode electrode are disposed in this order (figure 2), and an electron beam passing aperture (figure 4, 47, page 3, lines 17-24) provided in a surface of the first focusing electrode (44) facing the second focusing electrode (46) and a surface of the second focusing electrode facing the first focusing electrode is a single opening (47, page 3, line 18) common to three electron beams, and the single opening (47) is positioned between a position of the prefocus lens (42) and a position of the main lens (page 2, lines 55-56).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

⁽a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at

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the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 3 is rejected under 35 U.S.C. 103(a) as being unpatentable over

Trinchero (EP 0 889 500) which is Applicant's admitted prior art in view of Matsuo
(US 2002/0153825).

Trinchero further discloses the focusing electrode (figure 4, 44) provided with the single opening (47) has a tubular wall surface surrounding the three electron beams.

Trinchero does not disclose a hole is provided in lateral surface portions in the wall surface that intersect a horizontal axis.

Matsuo discloses a focusing electrode (figure 4, 27) used in an electron gun (figure 1) having holes (61) provided in lateral surface portions in the wall surface that intersect a horizontal axis, for the purpose of preventing a velocity modulation magnetic field generated by the velocity modulation coils from interfering with a deflection magnetic field (abstract).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to have holes provided in lateral surface portions in the wall surface that intersect a horizontal axis disclosed by Matsuo in the electron gun disclosed by Trinchero, for the purpose of preventing a velocity modulation magnetic field generated by the velocity modulation coils from interfering with a deflection magnetic field.

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Claim 4 is rejected under 35 U.S.C. 103(a) as being unpatentable over Trinchero (EP 0 889 500) which is Applicant's admitted prior art in view of Takekawa (US 2002/0079820).

Trinchero discloses all of the claimed limitations except for the vertical width of the single opening near positions through which the three electron beams pass is smaller than that at the other positions.

Takekawa discloses a focusing electrode (figure 2A) used in an electron gun (figure 1) having a vertical width of opening near positions (G3-12) through which the three electron beams pass is smaller than that at the other positions (G3-11), for the purpose of minimizing a vertical dimension of a region for passing the electron beam (abstract).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to have a vertical width of opening near positions through which the three electron beams pass is smaller than that at the other positions disclosed by Takekawa in the electron gun disclosed by Trinchero, for the purpose of minimizing a vertical dimension of a region for passing the electron beam.

Response to Arguments

Applicant's arguments with respect to claims 1-6 have been considered but are most in view of the new ground(s) of rejection.

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Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Contact information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Bumsuk Won whose telephone number is 571-272-2713. The examiner can normally be reached on Monday through Friday, 8:00 am to 5:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimeshkumar Patel can be reached on 571-272-2457. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Bumsuk Won Patent Examiner JOSEPH WILLIAMS